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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/651,783	08/30/2000	Shuichi Kanno	NIP-198	2461
24956 75	590 11/15/2006		EXAMINER	
MATTINGLY, STANGER, MALUR & BRUNDIDGE, P.C.			NGUYEN, NGOC YEN M	
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SUITE 370		ART UNIT	PAPER NUMBER	
ALEXANDRIA, VA 22314			1754	
			DATE MAILED: 11/15/2006	4

Please find below and/or attached an Office communication concerning this application or proceeding.

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09/651,783 Examiner	KANNO ET AL.				
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LXammer	Art Unit				
Ngoc-Yen M. Nguyen	1754				
ears on the cover sheet with the c	orrespondence address				
IS SET TO EXPIRE 3 MONTH() TE OF THIS COMMUNICATION 6(a). In no event, however, may a reply be tim ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONED date of this communication, even if timely filed	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
aust 2006.					
					
	secution as to the merits is				
x parte Quayle, 1935 C.D. 11, 45					
4) Claim(s) 3,4,11-14,16 and 17 is/are pending in the application.					
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5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>3-4, 11-14, 16-17</u> is/are rejected.					
Claim(s) is/are objected to.					
election requirement.					
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Application Papers					
9) The specification is objected to by the Examiner.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
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have been received in Application ty documents have been received	on No d in this National Stage				
4) Interview Summary (Paper No(s)/Mail Dat 5) Notice of Informal Pa 6) Other:	te				
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DETAILED ACTION

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 3-4, 11-14, 16-17 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

Applicants are requested to point out support in the instant specification, by page and line numbers, for the limitations "a filter type mist separator ...such that the removed mist is then drained through a liquid waste outlet in a form of liquid or a gather of mist, and residual mists not removed by said mist removal means are discharged ...in said exhausting step" as required in the instant claims 3-4, 11, 17. Applicants point out that support for the limitation "wherein said step of removing mist...in said exhausting gas" can be found on page 5, line 10 to page 6, line 14 of the instant specification and Figures 2(A) and 2 (B). Such disclosure in the specification may provide sufficient support for the claimed limitation when the "mist removal means" is cyclone mist separator as shown in Figures 2(A) and 2(B), but not for the generic "mist removal means" as required in Applicants' claims because the claimed "mist removal

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means" can be a filter mist separator (as shown in Figure 3) or electric dust collector (Figure 4). There is no disclosure in the instant specification or in Figures 3-4 that there were 2 liquid outlets for the filter mist generator or the electric dust generator.

Applicants are also requested to point out support in the instant specification, by page and line numbers, for the limitation of "decomposing a toxic component containing at least one of SO₃, HF, NO, NO₂, ... produced by said decomposition of PFC ... at the rear stage of said PFC decomposition process". It should be noted that in the instant specification, it is disclosed that SF₆ and NF₃ are decomposed into SO₃, HF, NO, NO₂ (note equation 1 and 2 on page 4) and these decomposition products "can be removed from the decomposed gas by washing with water or an alkaline aqueous solution" (note page 4, lines 11-13), not by contacting with "a toxic component removing catalyst". Also, on page 12 of the instant specification, it is disclosed that PCF decomposition catalyst 8 and hazardous component removing catalyst 9 are packed into the PFC decomposition tower 1 and the hazardous component here means CO, SO₂F₂, and the like (note page 12, lines 3-8 and page 14, lines 18-25 which mention "SO₂F₂ decomposition catalyst"). There is no disclosure in the instant specification to indicate that the "decomposition products" from decomposing PFC and the "hazardous component" are the same, i.e., there is no disclosure to show that CO and SO₂F₂ are obtained after decomposing a PFC gas that contains at least one of SF₆ and NF₃. There is no support in the instant specification for the two-step decomposing process as now required in the instant claims.

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The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 3-4, 11-14, 16-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over EP 0 885 648 in view of either JP 11-216,455 or Lang et al (6,235,256).

EP '648 discloses a process for decomposing fluorine compounds, comprising the steps of contacting a gas flow containing the fluorine compounds, which comprises fluorine as a halogen element, and any of the elements carbon, nitrogen and sulfur as a compound with the fluorine, with a fluorine compound-decomposition catalyst in the presence of steam to hydrolyze the fluorine compound in said gas flow, wherein said gas flow containing said fluorine compounds is contacted with a catalyst comprising Al to convert said fluorine compounds to hydrogen fluoride (note claim 1). In the equation 4 and 5 on page 3 of EP '648, when SF₆ or NF₃ is being decomposed, SO₃ or NO is formed. In the embodiments 6 and 7, SF₆ or NF₃ is diluted with air or nitrogen, the resulting gas is contacted with a catalyst to decompose the fluorine compound. The decomposed gas is scrubbed in an alkaline scrubber (note page 10, lines 1-25).

EP '648 discloses that sulfur oxides such as SO₂, SO₃ and the like, and nitrogen oxides, such as NO, NO₂, and the like, are generated in some cases. In order to neutralize and eliminate these products, a method of scrubbing the decomposed gas by

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spraying an aqueous alkaline solution is desirable (note paragraph bridging pages 3-4). Thus, the scrubbing step is considered as the step of removing SO_x and NO_x from the washed gas.

For the second "decomposing" step, i.e. "decomposing a toxic component...at the rear stage of said PFC decomposing process", this claim is read in light of the specification that there are two separate catalysts, i.e. catalyst "8" and catalyst "9", to remove different components in the PFC gas simultaneously in a single process step (note instant specification, page 14, under "(Embodiment 1)". EP '648 discloses that the stream to be treated can contain more than one fluorine compound and the catalyst can contains at least one element selected from the group consisting of Zn, Ni, Ti, Fe, Sn, Pt, Co, Zr, Ce, and Si in additional to Al (note page 3, lines 8-15). Thus, when more than 1 element was used in addition to Al, the first element with Al is considered as the claimed "decomposition catalyst" and the second element with Al is considered as the claimed "toxic component decomposition catalyst".

The difference is EP '648 does not disclose the step of removing SO_x or NO_x from the decomposed gas after scrubbing by passing the gas after the scrubbing step through a cyclone or demister.

JP '455 discloses a process for treating an exhaust gas generated in a process of making printed circuit board by passing the exhaust gas through a catalytic thermal decomposition device 4 and the waste gas cleaning device 5 and discharged as a harmless exhaust gas 6 (note English abstract). As shown in Figure 3, the exhaust gas after scrubber 5 is introduced into a cyclone 8. Here the moisture within the exhaust

gas is removed and recycled back to the scrubber 5 thereby minimizes the requirement of fresh scrubbing liquid. JP '455 further teaches that a demister can be used instead of a cyclone (note paragraph 0036).

For the limitation of "the removed mist is then drained through a liquid waste outlet... in the emission said of said gas exhausted in said exhausting step", since JP '455 desires to recycle the moisture back to be used as scrubbing liquid, it would have been obvious to one skilled in the art to recover such moisture in the form of a liquid and it would also have been obvious to one skilled in the art to repeat the moisture removing step and to select proper equipment to effectively recover and recycle as much as possible of the moisture in the exhaust gas.

For the instant claim 16, it would have been obvious to one of skill in the art to optimize the inlet velocity to effectively remove the moisture from the exhaust gas and to select an appropriate material for the construction of the cyclone to withstand the condition of the process.

It would have been obvious to one of ordinary skill in the art at the time of the invention was made to pass the exhaust gas after the scrubbing step in EP '648 to a cyclone or demister, as suggested by JP '455, because by doing so, the moisture can be removed from the gas and recycled to the scrubber thereby minimizes the requirement of fresh scrubbing liquid. Such step would inherently remove any remaining NO_x or SO_x from the washed gas.

Alternatively, Lang '256 can be applied. Lang '256 discloses a process for scrubbing acid gases. In the process, the improvement is a demister arranged at a

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location after the liquid droplets have been sprayed by the spray means into the flow path of the flue gases (note column 3, lines 8-43 and claim 1).

It would have been obvious to one of ordinary skill in the art at the time of the invention was made to pass the exhaust gas of EP '648 to a demister, as suggested by Lang '256 in order to obtain the advantages as disclosed in Lang '256 (note, for example, column 1, lines 44-50).

Claims 3-4, 11-14, 16-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kanno et al (PGPub US 2001/0001652) in view either JP 11-216,455 or Lang et al (6,235,256).

Kanno '652 is an US counterpart of EP '648.

Kanno '652 discloses a process as mentioned for EP '648 (note claim 1, Examples 11-12).

The difference is Kanno '652 does not disclose the step of removing NO_x or SO_x after the scrubbing steps.

JP '455 or Lang is applied to teach the step of passing the gas after the scrubbing step to a cyclone or demister.

Applicant's arguments filed August 25, 2006 have been fully considered but they are not persuasive.

Applicants argue that the filter type mist separator remove mist from the gas passing there through and the portion of the mist removed by the filters 32 and 33 drops

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to the bottom of the lower chamber of the filter type separator shown in Fig. 3 and is removed out through the outlet at the bottom thereof.

In Applicants' specification, page 6, lines 15-28, it is disclosed that the gas is introduced into the cylinder from the bottom portion and exhausted from the top portion and the "liquid accompanied with the gas passed through the filter is exhausted to outside of the cylinder through liquid outlet 36", there is disclosure of the mist removed by the filters drops to bottom as argued by Applicants.

Applicants argue that no applied reference discloses that the mist is removed through two stages.

As stated in the above rejection, JP '455 or Lang '256 is applied to teach the mist removal step and it would have been obvious to repeat the mist removal step in order to remove as much mist as desired.

Applicants argue that the matter of whether the water is recycled is a different technical issue from Applicants' claimed invention.

Water recycling is a motivation for removing the mist from the exhaust gas. Such motivation does not have to be the same the reason for removing the mist in Applicants' claimed invention.

Applicants argue that EP '648 does not teach the steps of removing decomposition products from the gas washed in the washing step, wherein a waste including a mist remains after the removing of the decomposition products; removing the mist from the waste remaining after the washing.

As stated in the above rejection, EP '648 discloses the washing step to remove the decomposed products. The only step missing from EP '648 is the mist removal step and JP '455 or Lang '256 is applied to teach such step.

Applicants argue that EP '648 discloses a lower temperature for the decomposing of SF₆ and NF₃.

Applicants' claims do not require any temperature for the decomposing step.

Applicants argue that does not disclose that some decomposition products survive the washing step and such product may be removed from the mist before atmospheric emission.

Again, the motivation for removing the mist as stated in the above rejection does not have to be the same reason for performing the same step in Applicants' claimed invention.

Applicants argue that JP '455 only discloses moisture in the washed waste gas, which is passed through a mist removal step.

It should be noted that in both JP '455 and in EP '648, an aqueous alkaline solution is used to remove toxic compounds from the exhaust gas, thus, it would have been obvious to one of ordinary skill in the art, at the time the invention was made to removal the moisture in the mist in the process of EP '648, as suggested by JP '455, in order to recycle it back to the scrubbing or washing step.

Applicants argue that there is no description about the removal of HF, SO₃, and NO before exhausting into the atmosphere.

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A scrubbing processing is disclosed in EP '648 to move the above mentioned compounds, as stated in the above rejection.

Applicants argue that EP '648 accepts that the exhaustion of mere moisture.

Even if that was true, JP '455 still provide a motivation to recover such moisture by performing a mist removing step in order to recycle the moisture back to the scrubbing step.

Applicants argue that JP '455 does not describe any concrete feature about a mist removal means as now claimed.

JP '455 fairly teaches that a cyclone or a demister can be used to remove the moisture, it would have been obvious to one skilled in the art to select the proper type to maximize the removal of moisture because these are known and conventional means in the art.

The rejections using Lang and Kanno are maintained for the same reasons as stated above.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not

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mailed until after the end of the THREE-MONTH shortened statutory period, then the

shortened statutory period will expire on the date the advisory action is mailed, and any

extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

the advisory action. In no event, however, will the statutory period for reply expire later

than SIX MONTHS from the date of this final action.

The prior art made of record and not relied upon is considered pertinent to

applicant's disclosure.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Ngoc-Yen M. Nguyen whose telephone number is (571)

272-1356. The examiner is currently on Part time schedule.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Mr. Stanley Silverman can be reached on (571) 272-1358. The fax phone

numbers for the organization where this application or proceeding is assigned are (703)

872-9306 or (571) 273-8300.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed (571) 272-1700.

Ngoc-Yen M. Nguyen

Primary Examiner

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nmn

November 13, 2006